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257	Class	Subclass	ISSUE CLASSIFICATION
164			

6491843

6491843

754.5

212W	O.I.P.E.	PATENT DATE
SCANNED <u>142</u>	Q.A. <u>LTO</u>	DEC 10 2002

SCANNED

Q.A

PATENT DATE

DEC 10 2002

APPLICATION NO. 09/526286	CONT/PRIOR D	CLASS 216 252	SUBCLASS 79,1	ART UNIT 1746 1743	EXAMINER Goudreau
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Certificate

JUL 13 2004

Slurry for chemical mechanical polishing silicon dioxide

of Correction

PTO-2040
12/89[illegible]

Formal Drawings: 4 sheets set 1

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg. 4	Figs. Drwg. 4	Print Fig. 3	Total Claims 10	Print Claim for O.G. 1
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) (Date)			NOTICE OF ALLOWANCE MAILED	
	_____ GEORGE GOUDREAU PRIMARY EXAMINER _____ (Primary Examiner) (Date)			6/13/02	
ISSUE FEE 14					
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent. No. _____ _____ _____	_____ (Legal Instruments Examiner) (Date)			Amount Due \$128.00	Date Paid 9-3-02
				ISSUE BATCH NUMBER	

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